Development and ordering of mounds during metal(100) homoepitaxy

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Abstract
Scanning-tunneling microscopy studies combined with atomistic modeling for Ag/Ag(100) homoepitaxy reveal complex growth behavior at 300 K: initial smooth growth up to ∼25 ML, where three-dimensional (3D) mounds develop from 2D islands; then an extended regime of mound steepening for ∼1000 ML producing unexpected rough growth; and finally an asymptotic regime with cooperative mound ordering and coalescence dynamics quite distinct from that in systems with up-down symmetry. The steepening regime is compressed upon lowering temperature, so while initial growth is rougher, asymptotic growth is actually smoother.

Keywords
metal, silver, atomic particle, dynamics, film, growth, model, physical phenomena, scanning tunneling microscopy, temperature

Disciplines
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Comments

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The evolution of complex patterns in physical systems occurs in a variety of phase separation and domain-boundary-driven coarsening processes. Examples can be found in alloy systems, complex fluids, and surface adlayers. There is considerable experimental and theoretical interest in analyzing these patterns, often focussing on long-time asymptotic behavior. The latter is of particular interest as it typically falls into one of a few “universality classes” determined by the basic characteristics of the process (symmetry, domain degeneracy, dimension) rather than by the finer details. Another example receiving much attention recently is formation of 3D mounds (multilayer stacks of 2D islands) during epitaxial growth, a phenomenon of significance for various thin film deposition technologies. An extra complication here is a subtle interplay between the observed lateral coarsening of the array of mounds, and the kinetic roughening of growing film. In fact, many aspects of the morphological “landscapes” developing in these growing films have yet to be carefully examined or fully understood. Thus, a basic goal is to develop atomistic models, which can predict quantitatively these morphologies.

Mound formation during epitaxial growth is often associated with step-edge (SE) barriers to downward transport, which promote reflection of diffusing atoms from descending steps and incorporation at ascending steps. This produces a destabilizing lateral mass current \( J_{\text{up}} \) in the uphill direction. Mound slopes increase initially, but may stabilize if there is sufficient buildup of a downhill current \( J_{\text{down}} \) (e.g., due to “downward funneling” of depositing atoms at step edges) counterbalancing \( J_{\text{up}} \). An extreme regime of mound formation is often found in metal(111) homoepitaxial systems due to large SE barriers. These produce the near-Poisson film height distributions for Ag/Ag(111) (Refs. 3 and 4) and Pt/Pt(111), with persistent mound steepening, as well as a lack of coarsening for Pt/Pt(111). Contrasting behavior is seen in metal(100) systems such as Cu/Cu(100) (Ref. 6) and Fe/Fe(100), where slope selection is rapid, tying mound coarsening to film roughening. Metal(100) systems are generally believed to have low SE barriers, prompting view that Ag/Ag(100) growth is smooth, contrasting Ag/Ag(111). We shall show, however, that Ag/Ag(100) growth is more complex than any of the above scenarios.

From a theoretical perspective, there is intense interest in characterizing asymptotic roughening and mound coarsening mechanisms. Simple continuum models with up-down symmetry have been applied to compare behavior in (111) and (100) systems, noting subtle topological effects in the latter. But do these reflect behavior in real systems which lack up-down symmetry? One should also scrutinize comparisons made with experiment, where data is often available only for a single temperature \( (T) \) and limited range of film thickness.

In this paper, we provide a detailed and comprehensive picture of kinetic roughening and mound evolution for Ag/Ag(100) film growth between 190 and 300 K. This is achieved by integrating high-resolution low-energy electron diffraction (LEED) studies (up to \( \sim 10 \) monolayers or ML), variable-temperature scanning tunneling microscopy (VTSTM) studies (up to \( \sim 100 \) ML), and kinetic Monte Carlo (KMC) simulations of a realistic atomistic growth model (up to \( \sim 2000 \) ML). Modeling recovers all observed features of 25 ML films deposited from 175 to 300 K, and is used to predict evolution of much thicker films. Furthermore, it elucidates key aspects of atomistic processes underlying growth (e.g., nonuniform SE barriers, inhibited kink rounding below 230 K). As expected, initial growth is fairly smooth at 300 K, and rougher at \( \sim 200 \) K, where small SE barriers inhibit smoothing. Contrary to common belief, we find that exactly the opposite is true for thick films. This is due to a regime of mound steepening and rapid roughening which extends for \( \sim 1000 \) ML at 300 K, but which is much compressed at \( \sim 200 \) K. Our modeling also reveals subtle aspects of morphological evolution in the subsequent asymptotic slope-selection regime including complex mound ordering, annihilation, and coalescence dynamics, which reflects strong up-down symmetry breaking and which is very different from behavior observed in abovementioned continuum formulations of moundng.

Experiments were performed in a UHV chamber with base pressure \( <10^{-10} \) Torr. Films were produced by evaporative deposition of Ag onto the Ag(100) single-crystal surface between 190 and 300 K, the temperature regime of mound formation, with a flux of \( F \approx 0.02 \) ML/s. Nanostructure evolution was monitored with an Omicron VTSTM. Specifically, we determine the film roughness \( W \) (in units of the interlayer spacing \( b = 2.04 \) Å) and the height-difference correlation function \( H(r) \) (mean-square surface height difference versus lateral separation \( r \)). Oscillations in the latter reflect a partially ordered array of mounds, the first minimum
roughly corresponding to the mean mound “diameter” $L_D$. We also directly determine the mound density $N_m$ and thus the mean mound separation $L_s = 1/\sqrt{N_m}$. For the initial stage of growth, VTSTM statistics for $H(r)$ are poorer, so we instead extract lateral correlation lengths $L_c \approx 1/d^*$, where $d^*$ is the inverse ring diameter of LEED profiles obtained during deposition in a separate UHV chamber. We have previously characterized the morphology of 25 ML films versus $T$, but all the results reported here for kinetic roughening and mound coarsening are new.

First, we describe our VTSTM results for kinetic roughening, the interpretation of which is facilitated by comparison with KMC simulations of our atomistic model described below. Experimental data (symbols) and simulation results (curves) for $W$ versus coverage $\theta$ are shown in Fig. 1 for various $T$. At 300 K, one finds distinct regimes of initial “smooth” growth up to $\sim 25$ ML (consistent with Ref. 4), rapid “preasymptotic” roughening up to $\sim 1500$ ML (during which mounds steepen), and subsequent “asymptotic” slope selection (as checked in simulations) with slower roughening. The three regimes are compressed upon reducing $T$, so that asymptotic behavior is already achieved by $\sim 100$ ML at 190 K. The unexpected feature of very rough (asymptotic) growth at 300 K, compared with smoother growth at $\sim 200$ K, is explained below. Roughening behavior can be described in terms of an effective exponent $\beta_{\text{eff}} = d(\ln W)/d(\ln \theta)$, which varies strongly with $\theta$ for higher $T$, but less so at 190 K. From simulations, $\beta_{\text{eff}}$ has low values in the initial regime (e.g., $\beta_{\text{eff}} \approx 0.2$ at 300 K), high values in the preasymptotic regime (which peak at $\beta_{\text{eff}} \approx 0.8$ at 300 K, 0.75 at 260 K, 0.65 at 230 K, and 0.45 at 190 K), and lower “asymptotic” values of $\beta_{\text{eff}} \approx 0.3$ at 190 K, and $\sim 0.25$ for higher $T$. Just using the experimental data suggests that $\beta_{\text{eff}} \approx 0.5$–0.6 for 230–300 K, and $\beta_{\text{eff}} \approx 0.4$ at 190 K, giving a superficial picture of the complex growth behavior.

Next, we describe the observed lateral mound coarsening behavior up to $\sim 100$ ML. The effective coarsening exponent is defined as $n_{\text{eff}} = d(\ln L)/d(\ln \theta)$, where $L$ measures lateral size (see above). Limited statistics preclude precise analysis. However, experimental values for $L_D$ and $L_S$ in the range of

![FIG. 2. Lateral mound size $L$ vs coverage $\theta$ for growth at 190, 230, 260 K (bottom to top). (a) Experimental: $L_D$ ( ), $L_s$ ( ). Measured island densities at 0.1 ML are used to estimate $L_D$ for lower $\theta$. (b) Model predictions: $L_s$ (gray curves), and $L_D$ along close-packed (black dashed) and open (black solid) step directions; $a = 2.89$ Å is the surface lattice constant.](image-url)
$E_{SE}$ for downward hops at close-packed [110] step edges, but no SE barrier at open or kinked step edges. This choice of nonuniform SE barrier\cite{18} is motivated by semiempirical studies of energetics.\cite{19} Finally, we must prescribe the periphery diffusion of adatoms at island edges. In our simplest model,\cite{17} such adatoms move immediately to double-bonded kink sites, even if this involves kink rounding. This "efficient kink rounding" (EKR) model reasonably describes growth coalescence of islands in the same layer, which is key to predicting $L_D$. In fact, choosing $E_{SE}=0.07$ eV, it recovers the observed $W$ and $L_D$ in 25 ML films for all $T \geq 230$ K (see Fig. 3).

The EKR model produces near-square islands whose [110] edges have a "high" ES barrier. However, kink rounding is likely inhibited at lower $T$, producing irregular island shapes with a higher population of kinked step edges having no ES barrier. This explains why the EKR model overestimates $W$ for 25 ML films deposited at lower $T$. Thus, we refine our model to incorporate "restricted kink rounding" (RKR) controlled by a barrier $E_{KR}$ (which must exceed the low barrier of 0.25 eV for hopping along perfect [110] step edges\cite{15}). Figure 3 shows that $W$ for 25 ML films at low $T$ depends very sensitively on $E_{KR}$, which is selected as 0.41 eV (for $r_{edge}=10^{12}$ s$^{-1}$) to match the observed behavior. To summarize, reentrant smooth growth of $\sim$25 ML films at low $T$ is due in part to enhanced downward funneling (note EKR model results), and in part to the development of irregular islands (resulting from RKR) with no ES barrier along kinked step edges.

Our model successfully reproduces the key features of roughening and mound coarsening observed for growth up to 60–100 ML (see Figs. 1, 2, 4). Thus, we believe it reliably predicts growth for thick films, including the extended mound steepening regime, and the transition to and evolution in the slope selection regime. The following discussion focuses on these regimes, comparing predicted behavior with various existing concepts and theories for mound coarsening.

**Preasymptotic mound steepening regime.** Perhaps the key observation here is that the smaller island separations, and thus smaller lateral mound sizes $L_D$ at low $T$ result in a more rapid increase in slope, and thus earlier slope selection.\cite{20} Unexpected rough growth at 300 K is a consequence of the feature that large island separations (and thus $L_D$) allow prolonged steepening. It is instructive to compare observed behavior with Goluovic's predictions of rapid roughening with $\beta=\frac{1}{2}$, and slow coarsening with $n_{eff}=\frac{1}{2}$ from simple continuum models for growth without slope selection,\cite{10} and with a "relaxation term" tailored to irreversible island formation.\cite{5} While it is too simplistic to say $\beta=\frac{1}{2}$ for this system, this analysis does seem to capture the basic behavior in the preasymptotic regime. A more general perspective motivated by previous simulations,\cite{21} which seems to apply here, is that coarsening may be slow when steepening is operative, due to competition between these processes. Finally, it is appropriate to note that the possibility of rapid roughening following initial smooth growth for Ag/Ag(100) at 300 K was suggested by previous x-ray scattering studies,\cite{4} but it was not pursued or explained.

**Asymptotic slope-selection regime.** Values of exponents $\beta=n_{eff}$ from 0.25–0.3 are also consistent with standard continuum models\cite{22} for growth.\cite{11,12} The trend of (slightly) higher $n_{eff}$ for lower $T$ differs from previous simulations where inhibited kink rounding produced lower $n_{eff}$,\cite{12} suggesting that the nonuniform SE barrier in our system likely

\begin{figure}
\centering
\includegraphics[width=0.5	extwidth]{fig3}
\caption{W vs T for 25 ML films predicted by the atomistic model for various kink rounding barriers $E_{KR}$ (shown). EKR corresponds to $E_{KR}=0$. Experimental values are shown as symbols.}
\end{figure}

\begin{figure}
\centering
\includegraphics[width=0.5	extwidth]{fig4}
\caption{Film morphologies (50×50 nm$^2$) at 230 K from: (a) STM experiment; (b) simulations.}
\end{figure}

\begin{figure}
\centering
\includegraphics[width=0.5	extwidth]{fig5}
\caption{Mound ordering at 190 K in our model for 100 ML (130×130 nm$^2$) and 5000 ML (300×300 nm$^2$) films; [100] steps are horizontal. Insets: power spectrum for mound centers.}
\end{figure}
produces modified behavior. However, a major difference in the dynamics of mounds emerges between our model and previous continuum models incorporating up-down symmetry. In the latter, a checkerboard pattern of alternating mounds and pits (inverted mounds) develops, and evolution is enslaved to the dynamics of rooftop or valley floor “defects.”

Our model for Ag/Ag(100) growth reveals a roughly isotropic distribution of mounds at the beginning of the asymptotic regime, from which develops ordered \(1 \times 1\) patches of mounds with square bases along the close-packed directions (Fig. 5). Correspondingly, the power spectrum of the distribution of mound centers evolves from an isotropic ring to a fourfold symmetric pattern (Fig. 5), and \(L_D\) in [110] and [100] step directions start equal, but ultimately differ by \(\sim v^2\) [Fig. 2(b)]. This reflects strong up-down symmetry breaking, with valley floors (which separate most mounds) greatly favored over rooftops. Mound dynamics differs qualitatively from Ref. 11. For disordered arrays of square mounds, corner-to-corner coalescence seems to predominate. However, ordered \(1 \times 1\) regions of side-by-side mounds display a more complex and cooperative dynamics: fluctuations in size of adjacent mounds trigger annihilation of the smaller neighbor, leading to corner-to-corner coalescence (and other synchronous annihilation) events, see Fig. 6. Corner-to-corner coalescence requires considerable disruption of the ordered \(1 \times 1\) pattern.

In summary, we have presented a detailed picture of growth in Ag/Ag(100) homoepitaxy, revealing unexpected rough growth at 300 K due to prolonged mound steepening, and providing a picture of the highly cooperative long-time dynamics of mounds with selected slope.

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18. Our modeling with a uniform ES barrier fails to describe observed roughening.
20. This applies even though selected slopes are somewhat higher at lower \(T\) (Ref. 17).
22. Here the relaxation term has the traditional Mullins form; this term is present and eventually dominates even in systems with irreversible island formation (Ref. 16).